Electronic Supplementary Material (ESI) for Journal of Materials Chemistry C.

Supporting Information

Tungstate nanosheet ink as a photonless and electroless chromic device

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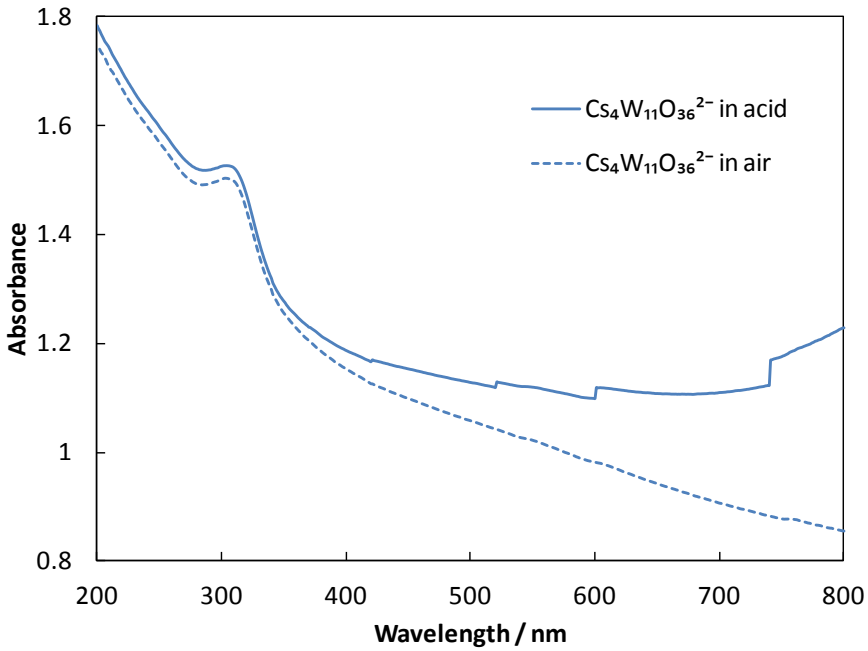

Fig. S1 UV-Vis spectra measured by reflection mode

Absorption spectra of thin films were recorded by a reflectance mode without using integration sphere unit. We could clearly observe the color change without using diffuse reflectance method. Absorbance curve after dipping in acid was discontinuous, since we scanned from the longer wavelength region and the film was decolored during the scanning.

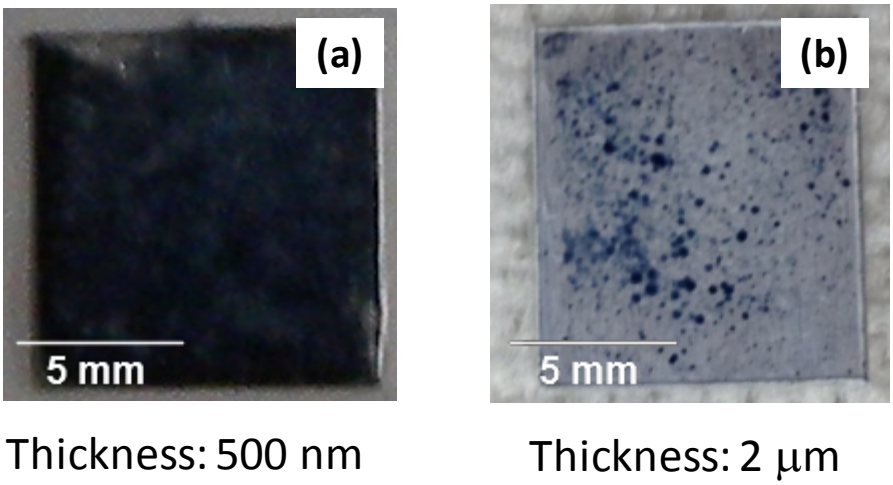

Fig. S2 Photos of thin films of cesium tungstate nanosheet after coloration. Thicknesses are 500 nm (a) and 2μm (b), respectively.

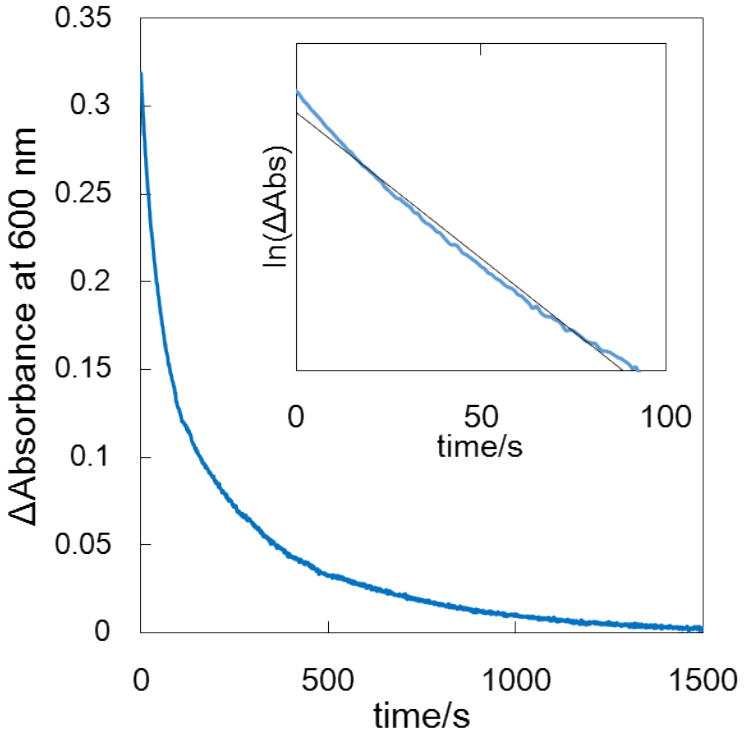

Fig. S3 Decay in color (at 600 nm) for thin films in air after the dipping in alkali solution (pH: 10). Inset shows the relationship between natural logarithm and time.